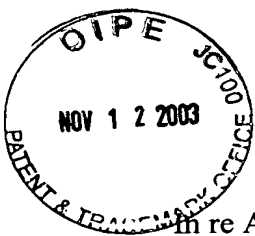


1753



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of:

Seiichiro TACHIBANA et al.

Confirmation No.: 3891

Serial No.: 10/611,853

Examiner: Unknown

Filed: July 3, 2003

Group Art Unit: 1753

Title: ETHER, POLYMER RESIST COMPOSITION AND PATTERNING PROCESS

**PRELIMINARY AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Prior to initial examination, please amend the above-identified application as follows.

Amendments and/or additions to the **Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 9 of this paper.